

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In Re Application of:	)	
	)	
Kloster, et al.	)	
	)	
U.S. Serial No: 09/820,079	)	Examiner: Loke, Steven Ho Yin
	)	
Filed: March 28, 2001	)	Art Unit: 2811
	)	
For: <b>STRUCTURE IN A</b>	)	
<b>MICROELECTRONIC DEVICE</b>	)	
<b>INCLUDING A BI-LAYER FOR</b>	)	
<b>A DIFFUSION BARRIER AND</b>	)	
<b><u>AN ETCH STOP LAYER</u></b>	)	
Commissioner for Patents		
P.O. Box 1450		
Alexandria, VA 22313-1450		

**AMENDMENT AND RESPONSE**

Dear Sir:

This is in response to the Office Action mailed May 26, 2006. Applicant respectfully requests the Examiner to enter the following amendments and consider the following remarks.

**Amendments to the Claims** are reflected in the listing of claims that begins on page 2 of this paper. **Remarks/Arguments** begin on page 7 of this paper.